

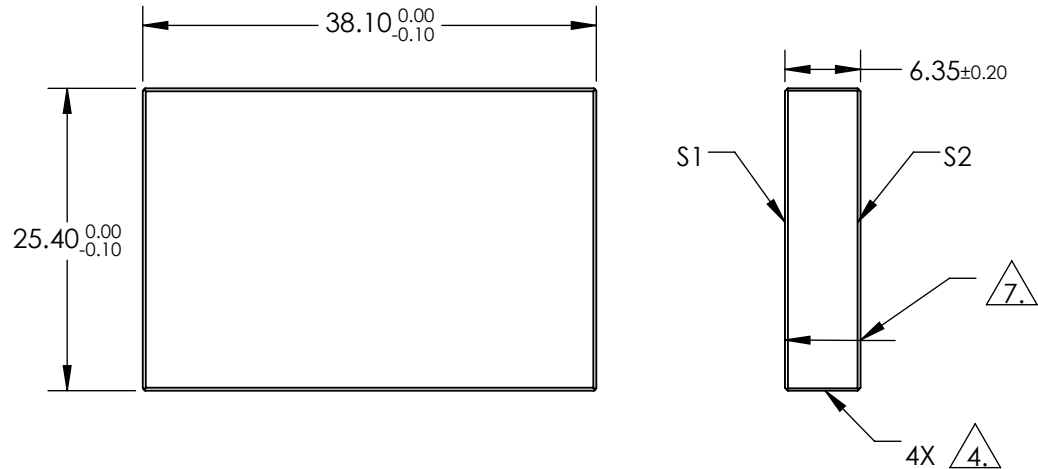
NOTES:

1. SUBSTRATE:
Fused Silica
2. SURFACE S1 TO BE PARALLEL TO SURFACE S2 TO WITHIN <3 ARCMINS
3. COATING (APPLY ACROSS COATING APERTURE)

S1: R(ABS) >99.8% @ 532nm
 R(ABS) >99.5% @ 523 - 537nm
 DAMAGE THRESHOLD,
 PULSED: 15 J/cm² @ 532nm, 20ns, 20Hz
 CW: 1 MW/cm² @ 532nm

S2: NONE

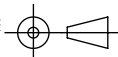
4. FINE GROUND SURFACE
5. CLEAR APERTURE AND COATING APERTURE ARE CENTERED ON SURFACE
6. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS APPLY ACROSS CLEAR APERTURE
7. ARROW ON EDGE WITH LASER ETCH, PENCIL, OR PERMANENT INK POINTS TOWARDS SURFACE S1




**FOR INFORMATION ONLY:
 DO NOT MANUFACTURE
 PARTS TO THIS DRAWING**

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
 DIMENSIONS ARE FOR REFERENCE ONLY

	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	10-5	COMMERCIAL POLISH
SURFACE FLATNESS	0.10 WAVE	N/A
MIN CLEAR APERTURE	21.59 x 32.39	N/A
MIN COATING APERTURE	21.59 x 32.39	N/A
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION 

ALL DIMS IN mm

 **Edmund Optics®**

TITLE: 25.4 x 38.1mm 532nm 45°, Nd:YAG Laser Line Mirror

DWG NO: 39644

SHEET 1 OF 1